



Attorney Docket No. CIT.PAU.01

Patent  
CIT.PAU.01

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

IN RE APPLICATION OF:  
SCHERER ET.AL.

SERIAL NO. : 10/068,283

FILED: FEB. 5, 2002

FOR: DRY ETCHING AND MIRROR  
DEPOSITION PROCESSES  
FOR SILICONE ELASTOMER

Examiner: R. McDonald

Group Art Unit: 1753

*Douglas J. Scherer*  
*Jan 21 2004*  
*JM*

AMENDMENT AFTER FINAL

Hon. Commissioner of Patents and Trademarks  
Washington DC 20231

Sir:

In reply to the Final Office Action mailed Jan. 23, 2004, please enter the following amendments and consider the following remarks.

Claims 1 – 20 were original in the application. Claims 16 – 20 were withdrawn and cancelled without prejudice. Claims 2, 3 and 5 – 13 have been allowed. Claim 4 has been indicated as allowable and has been amended. Claims 1, 4, 14, 15, and 21 have been amended. Therefore, claims 1, 4, 12 – 15, and 21 – 25 are submitted for as being set forth in a clearly allowable condition or at least in better form for appeal.